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Strain effects on the spectra of spontaneously ordered $Ga_x In_{1-x}P$

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Spontaneous (111) CuPt-like ordering has been widely observed in Ga_xIn_{1-x}P lattice matched $(x=x_0)$ to a GaAs(001) substrate. This leads to a band-gap reduction ΔE_g and to a valence-band splitting ΔE_{12} . We explore here the consequence of the *coexistence* of (001) epitaxial strain (produced by selecting $x \neq x_0$ and (111) chemical ordering. This leads to distinct changes in ΔE_g and ΔE_{12} which could serve as new fingerprints of ordering.

Surface reconstruction-induced ordering¹ of III-V alloys leads to lowering of the band gap^{1-5} and to splitting of the valence-band maximum (VBM).^{1,3,4} These effects have been predicted theoretically for perfectly ordered⁶ as well as for partially ordered⁷ alloys, and have been seen in electroreflectance,² polarized photoluminescence,³ polarized piezoreflectance,⁴ and in spatially resolved cathodoluminescence.⁵ In these experiments, the composition x of the growing $Ga_x In_{1-x}P$ film was adjusted to the value $(x=x_0)$ which gives lattice matching to the GaAs(001) substrate. Consequently, in the absence of strain, both the bandgap reduction $\Delta E_g = E_g$ (ordered) $-E_g$ (random) and the valence-band splitting $\Delta E_{12} = E_1 - E_2$ were attributed to the chemical ordering seen independently in diffraction experiments.¹ However, even in the absence of ordering, pure misfit strain $(x \neq x_0)$ can also lead to valence-band splitting⁸ and to band-gap changes.⁹ In this letter we thus focus on the interesting case of the coexistence of chemical ordering in the direction G_{ord} with epitaxial strain $(x \neq x_0)$ in the direction $G_{\text{substrate}}$. This is different from the case of artificially grown strain layer superlattices in which the direction of layer modulation coincides with the direction of strain, so these effects add up colinearly. In contrast, in spontaneously ordered alloys the direction of chemical ordering $G_{\text{ord}} = (111)$ is different from the substrate orientation $G_{\text{substrate}} \cong (001)$. We will show that this noncolinear "vector" addition" of ordering and strain effects can lead to interesting changes in the band-gap reduction ΔE_g , valence-band splitting ΔE_{12} , and the functional interrelationship ΔE_g vs ΔE_{12} between them.

In imperfectly ordered $Ga_x In_{1-x}P$ alloy, successive (111) cation planes are not pure Ga and pure In, respectively, but $Ga_{x+\eta/2}In_{1-x-\eta/2}$ and $Ga_{x-\eta/2}In_{1-x+\eta/2}$, respectively. The degree of CuPt-type order is described by the long-range order parameter⁷ $0 \le \eta \le 1$. The epitaxial strain (perpendicular to the growth direction) is $\epsilon(x) = [a_s - a_f(x)]/a_f(x)$, where $a_f(x)$ and a_s are the lattice constants of the film and the substrate, respectively. All of our quantities will thus be denoted by the degree of order η and the strain $\epsilon(x)$. The band-gap reduction of the strained and ordered alloy $\Delta E_g(\eta,\epsilon) \equiv E_g(\eta,\epsilon) - E_g(0,0)$ is measured with respect to the gap of the random, strain-free alloy $E_g(0,0)$ at the same composition. In this reference system, the top of the valence

band is the sixfold degenerate Γ_{15v} state while the direct conduction-band minimum is the Γ_{1c} doublet. The degeneracy at the top of valence band is lifted by spin-orbit (SO) coupling, ordering(O) and strain(S). The corresponding splittings are denoted Δ^{SO} , Δ^O_{111} , and Δ^S_{001} , respectively. We will next describe their effects on the Hamiltonian assuming small deviations of x from x_0 (i.e., a linear theory).

Spin-orbit coupling is zero for the s-like Γ_{1c} state, while the six valence states $(x\uparrow, y\uparrow, z\uparrow, x\downarrow, y\downarrow, z\downarrow)$ are coupled by the 6×6 spin-orbit Hamiltonian given in Ref. 10. Both strain and ordering effects do not distinguish spin up and spin down, so each is described by two identical 3×3 matrices.

For (001) strain the valence (v) Hamiltonian is^{8,11}

$$H_{001,v}^{S}(\epsilon) = a_{v} \frac{\Delta V(\epsilon)}{V} + \frac{1}{3} \Delta_{001}^{S}(\epsilon) \begin{pmatrix} 1 & 0 & 0 \\ 0 & 1 & 0 \\ 0 & 0 & -2 \end{pmatrix}.$$
(1)

Here, a_v is the hydrostatic deformation potential of the valence band, $\Delta V(\epsilon)/V$ is the relative volume change, and $\Delta_{001}^{S}(\epsilon) = 3b[(C_{11}+2C_{12})/C_{11}]\epsilon$ is the crystal field splitting, where b is the tetragonal deformation potential and C_{ii} are the elastic constants.

For pure (111) chemical ordering the valence Hamiltonian is¹¹

$$H_{111,\nu}^{O}(\eta) = B_{\nu}(\eta) + \frac{1}{3} \Delta_{111}^{O}(\eta) \begin{pmatrix} 0 & -1 & -1 \\ - & 0 & -1 \\ -1 & -1 & 0 \end{pmatrix}.$$
(2)

Here, B_{v} is the ordering-induced shift of the valence-band energy center while $\Delta_{111}^{O}(\eta) = \Delta_{111}^{O}(\eta=1) \eta^2$ are the ordering-induced crystal filed splitting.⁷ Placing $H_{001,v}^{S}$ and $H_{111,v}^{O}$ on the two diagonal 3×3 blocks and adding the full 6×6 spin-orbit matrix,¹⁰ relative to the energy center of the top of valence band, the total valence Hamiltonian of (111) ordering plus (001) strain are:

$$H_{v} = \frac{1}{3} \begin{pmatrix} \Delta_{001}^{S} & -\Delta_{111}^{O} - i\Delta^{SO} & -\Delta_{111}^{O} & 0 & 0 & \Delta^{SO} \\ -\Delta_{111}^{O} + i\Delta^{SO} & \Delta_{001}^{S} & -\Delta_{111}^{O} & 0 & 0 & -i\Delta^{SO} \\ -\Delta_{111}^{O} & -\Delta_{111}^{O} & -2\Delta_{001}^{S} & -\Delta^{SO} & i\Delta^{SO} & 0 \\ 0 & 0 & -\Delta^{SO} & \Delta_{001}^{S} & -\Delta_{111}^{O} + i\Delta^{SO} & -\Delta_{111}^{O} \\ 0 & 0 & -i\Delta^{SO} & -\Delta_{011}^{O} - i\Delta^{SO} & \Delta_{001}^{S} & -\Delta_{111}^{O} \\ \Delta^{SO} & i\Delta^{SO} & 0 & -\Delta_{111}^{O} & -\Delta_{111}^{O} & -\Delta_{011}^{SO} & -\Delta_{011}^{S} \end{pmatrix} .$$
(3)

Solving Eq. (3) gives the valence-band levels (in decreasing order) E_1 , E_2 , and E_3 as a function of composition x (or strain ϵ) and degree of ordering η .

The energy for the conduction (c) band minimum is given by

$$E_c(\eta,\epsilon) = E_c(0,0) + a_c \frac{\Delta V(\epsilon)}{V} + B_c(\eta).$$
(4)

Here, $E_c(0,0)$ is the conduction-band energy of the strainfree random alloy at composition x, a_c is the deformation potential of the conduction band, and B_c is the orderinginduced conduction-band energy shift. Since only relative energy difference between two bands are generally measured, it is convenient to define the center of the three top of valence-band energies as our zero of energy and denote by $a = a_c - a_v$ and $B = B_c - B_v$ as the deformation energies of the average band gap $\bar{E}_g = E_c - \frac{1}{3}(E_1 + E_2 + E_3)$. For (001) strain the relative volume change is given by $\Delta V(\epsilon)/V = 2[(C_{11} - C_{12})/C_{11}]\epsilon$. The ordering induced average band-gap change is given by $B(\eta) = [\Delta E_g(1,0)]$ $+\frac{1}{3}\Delta_{111}^{O}(1,0)$] η^2 , where $\Delta E_g(1,0)$ is the band-gap reduction of the strain-free and fully order alloy relative to the perfectly random alloy. Hence, the conduction-band energy of Eq. (4) can be written as

$$E_{c}(\eta,\epsilon) = E_{g}(0,0) + \frac{1}{3}\Delta^{\text{SO}} + 2a \frac{C_{11} - C_{12}}{C_{11}}\epsilon + \left[\Delta E_{g}(1,0) + \frac{1}{3}\Delta^{O}_{111}(1,0)\right]\eta^{2}.$$
 (5)

The needed input data for evaluating Eqs. (3) and (5) are (i) the concentration dependent properties: $E_g(x)$, $\epsilon(x)$, $\Delta^{SO}(x)$, $C_{ij}(x)$, a(x), and b(x) of the random alloy (η =0) and (ii) the ordering dependent properties: $\Delta_{111}^O(1,0)$ and

TABLE I. Room-temperature experimental parameters (Ref. 12) used to calculate band-edge energy levels of $Ga_x In_{1-x}P$ as function of strain and ordering.

Properties	GaP	InP
a ₀ (Å)	5.4512	5.8687
E_{σ} (eV)	2.78	1.35
$\Delta^{\rm SO}$ (eV)	0.08	0.11
C ₁₁ (Gpa)	141	102
C_{12} (Gpa)	62	58
a (eV)	9.9	-6.4
b (eV)	-1.8	-1.6

 $\Delta E_g(1,0)$ of the fully ordered alloy. The first category of quantities are obtained for the random $\text{Ga}_x \text{In}_{1-x} P$ alloy by assuming the usual quadratic bowing form

$$P(x) = xP(GaP) + (1-x)P(InP) - b_P x(1-x),$$
(6)

where b_P is the bowing parameters for property *P*. For the spin-orbit splitting we use the bowing⁷ $b_{\Delta}so=-0.02$ eV, while for the direct gap the bowing is¹² $b_{E_g}=0.76$ eV. We assume zero bowing for lattice constant, elastic constants, and deformation potentials. These input values for Ga_xIn_{1-x}P are given in Table I. For the second category of quantities, we use our previously calculated band structure values⁷ $\Delta_{111}^O(1,0)=0.20$ eV and $\Delta E_g(1,0)=-0.32$ eV.

Using these input data we solve Eqs. (3) and (5), obtaining (a) the band-gap reduction $\Delta E_g[\eta, \epsilon(x)]$ and (b) the valence-band splitting $\Delta E_{12}[\eta, \epsilon(x)] = E_1[\eta, \epsilon(x)]$ $-E_2[\eta, \epsilon(x)]$. Figure 1 depicts these quantities as a function of the film composition x, while Fig. 2 shows them as a function of the degree η of long range order. The following are the important features:



FIG. 1. (a) The band-gap reduction $\Delta E_g(\eta, \epsilon) \equiv E_g[\eta, \epsilon(x)] - E_g[0,0]$ as a function of composition x at $\eta=0$ and $\eta=0.5$. The dashed horizontal line denotes $\Delta E_g(0,0)$. $x_0=0.516$ is the lattice-matched composition. (b) The valence-band splitting ΔE_{12} of the strained alloy with ordering as function of composition x at $\eta=0$ and $\eta=0.5$.

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FIG. 2. Same as Fig. 1, but plotted as function of η at compositions $x=x_0$, x=0.4 and x=0.6. Solid circles indicate our fit to the data of Ref. 4.

(i) Pure strain with no ordering $(x \neq x_0; \eta = 0$, see Fig. 1): (a) Here, any nonzero strain leads to a splitting of the VBM [Fig. 1(b)], but only tensile strain $(\epsilon > 0, x > x_0)$ leads to a band-gap *reduction*, while compressive strain $(\epsilon < 0, x < x_0)$ leads to a band-gap *increase* [Figs. 1(a) and 2(a)]. (b) The ΔE_{12} vs x and the ΔE_g vs x (or E_g vs x) curves have a cusp at $x = x_0$, reflecting the change of the VBM from light hole when $x < x_0$ to heavy hole when $x > x_0$. (c) The slope α for the light-hole gap E_g vs x is much smaller than the slope β for the heavy-hole gap. These features have been observed in strained random alloys of GaInP⁹ and GaInAs.⁹

(ii) Pure chemical ordering with no strain $(x=x_0; \eta\neq 0, see Fig. 2)$: (a) This leads universally to a valence-band splitting and to a band-gap reduction for any $\eta>0$. The solid circles in Fig. 2 show the recent piezomodulated reflectivity data of Alonso et al.⁴ We find that the η which fits the theoretical ΔE_g also fits the theoretical ΔE_{12} of the same samples. This then gives a "self-consistent" way of deducing η from optical measurements.⁷ (b) For the valence-band splitting, chemical ordering is analogous to compressive strain in that both yield a light-hole state at the top of the valence band.^{11,9,13} This ordering-induced reduction of the in-plan effective mass at the valence-band top (relative to the random alloy) would lead to larger exciton radii.

(iii) Coexistence of chemical ordering with epitaxial strain: (a) The coexistence of ordering $(\eta \neq 0)$ with strain $(x \neq x_0)$ is predicted to remove the cusp in the ΔE_g vs x and ΔE_{12} vs x curves (Fig. 1). (b) Chemical ordering is also predicted to reduce the dependence of ΔE_{12} on x, as illustrated by the flattening of the $\eta=0.5$ curve near $x=x_0$ in Fig. 1(b). (c) (001) strain increases the valence-band splitting produced by pure ordering, and vise versa [Figs. 1(b) and 2(b)]. This reflects the fact that the ordering-induced Δ_{111}^O and the strain-induced Δ_{001}^S crystal field splittings are complemented.



FIG. 3. The correlation between ΔE_{12} and ΔE_g as function of η at compositions $x = x_0$, x = 0.4 and x = 0.6. Solid circles indicate our fit to the data of Ref. 4.

tary, so the combined effect is larger than the individual one. (d) It is useful to plot the measured ΔE_g vs ΔE_{12} (Fig. 3). There are three domains in this plane: If the measured data fall on the $x = x_0$ line one can conclude that *chemical ordering* is the cause of both ΔE_g and ΔE_{12} . If data fall *above* the calculated $x = x_0$ line, *epitaxial strain* is the logical cause as well, as seen in Fig. 3 for the x=0.4 and x=0.6 lines. If the data fall *below* the line (as is the case for the high $|\Delta E_g|$ samples of Fig. 3), we have an effect that produce a lowering in the band gap *without* a concomitantly large valence-band splitting. A possible cause is *clustering of like atoms* (the initial stage of phase separation). Thus, a ΔE_g vs ΔE_{12} plot of measured points could be used as a guide for the relative importance of ordering, strain, and clustering/phase separation.

In summary, we have shown that measurements of ΔE_g and ΔE_{12} of $\operatorname{Ga}_x \operatorname{In}_{1-x} P$ films *mismatched* with the GaAs(001) can be used to observe new fingerprints of ordering. This includes the "rounding of the cusp" of ΔE_{12} vs x, flattening of the ΔE_{12} vs x curve, and the shifts in the ΔE_g vs ΔE_{12} curve. These predictions await experimental testing.

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¹For a recent review on spontaneous ordering, see A. Zunger and S. Mahajan in *Handbook of Semiconductors*, Vol. 3, 2nd ed. (Elsevrer, Amsterdam) and references therein (in press).